



HPL resistivity *measurement* in Pavia

P. Vitulo, G. Belli,

How do we (Pavia) measure HPL Resistivity ?

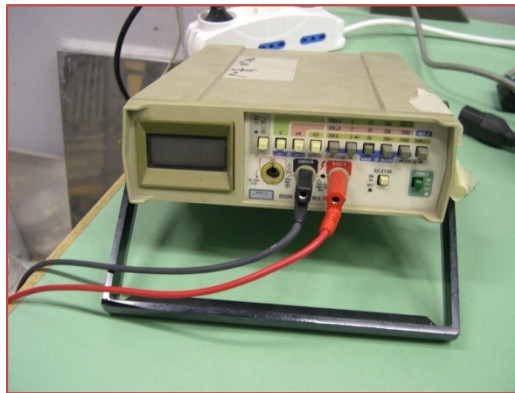
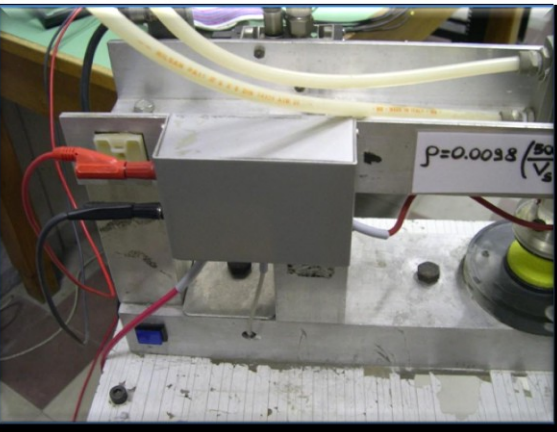
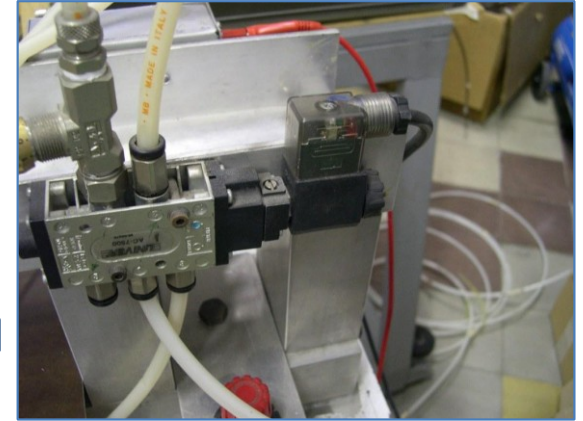
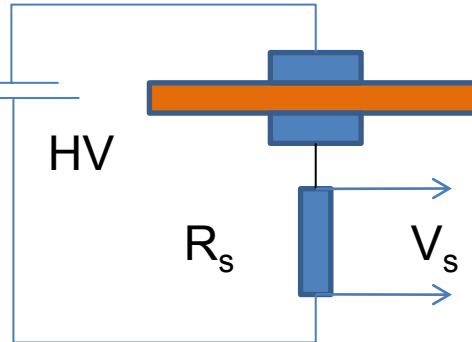
With:

- 1) A “Portable” instrument: wet measurements on 30 cm x 30 cm (max) samples

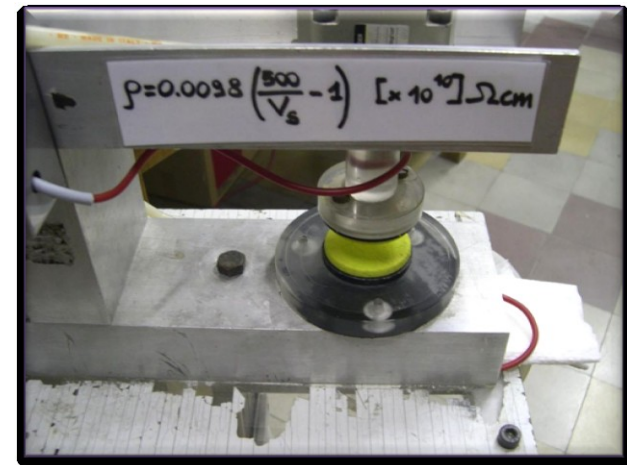
- 1) A “Fixed ” instrument: dry measurements on an entire panel (9 measurements in 9 different positions across the panel)

1) "Portable" Instrument:

a) Piston regulated by an electro-valve

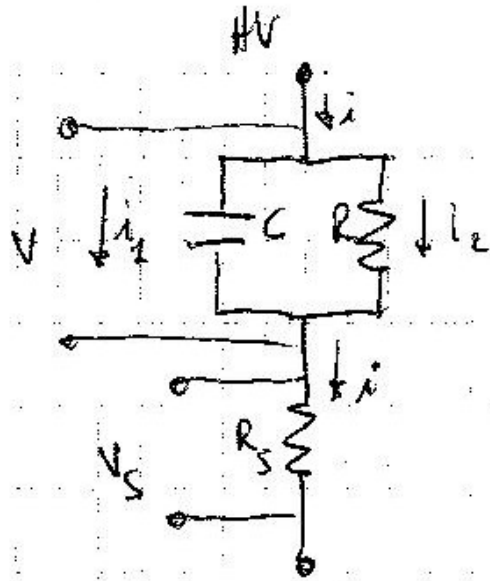


$$\rho = \left(\frac{HV}{V_s} - 1 \right) \times f(g) \times f(H, T)$$



b) We measure the voltage V_s across a resistor R_s in series to the piston

A model for the measurement.



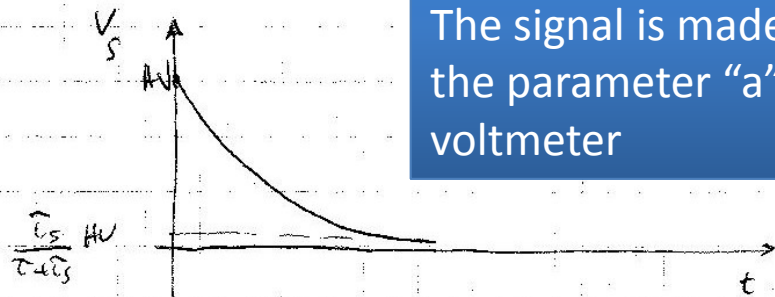
$$\begin{cases} i = i_1 + i_2 \\ V_s = i R_s \end{cases}$$

$$\begin{cases} \tau = RC \\ \tau_s = R_s C \end{cases}$$

$$V = \frac{1}{C} \int i_1 dt = i_2 R \quad i_2 = \frac{V}{R}$$

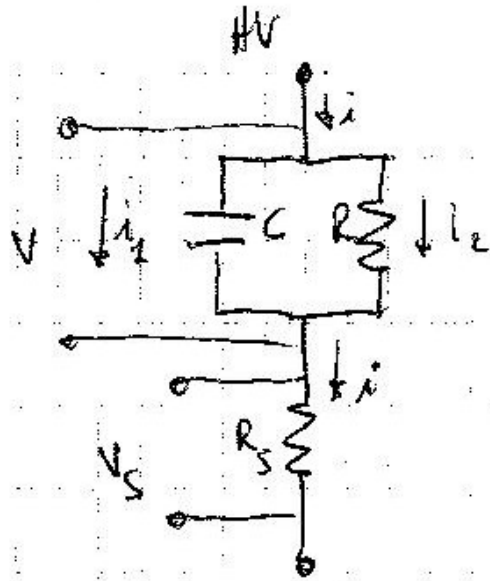
$$V_s = HV - V(t) = HV - \frac{\tau}{\tau + \tau_s} HV (1 - e^{-at}) = \frac{\tau_s}{\tau + \tau_s} HV + \frac{\tau}{\tau + \tau_s} HV e^{-at}$$

$$Q = \frac{1}{\tau} + \frac{1}{\tau_s}$$



The signal is made by a transient part (dielectric polarization) ruled by the parameter "a" and a steady part which is what we read in the voltmeter

A model for the measurement.



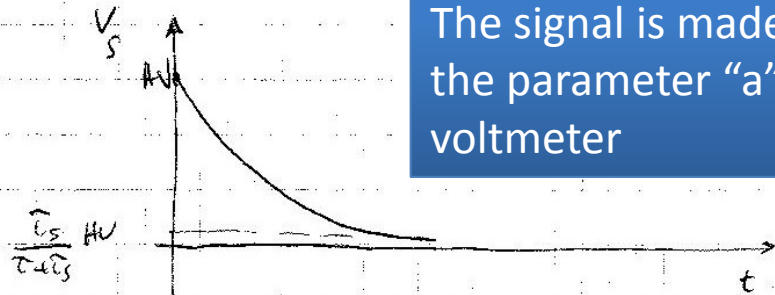
$$\begin{cases} i = i_1 + i_2 \\ V_S = i \cdot R_S \end{cases}$$

$$\begin{cases} \tau = RC \\ \tau_S = R_S C \end{cases}$$

$$V = \frac{1}{C} \int i_1 dt = i_2 R \quad i_2 = \frac{V}{R}$$

$$V_S = HV - V(t) = HV - \frac{\tau}{\tau + \tau_S} HV (1 - e^{-at}) = \frac{\tau_S}{\tau + \tau_S} HV + \frac{\tau}{\tau + \tau_S} HV e^{-at}$$

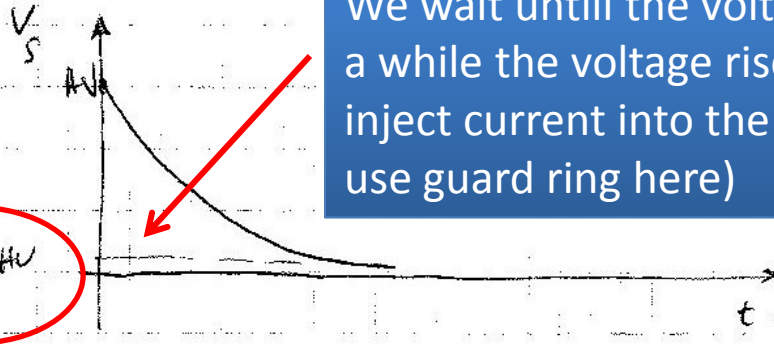
$$Q = \frac{1}{\tau} + \frac{1}{\tau_S}$$



The signal is made by a transient part (dielectric polarization) ruled by the parameter "a" and a steady part which is what we read in the voltmeter

$$V_s = HV - V(t) = HV - \frac{\tau}{\tau + \tau_s} HV (1 - e^{-at}) = \frac{\tau_s}{\tau + \tau_s} HV + \frac{\tau}{\tau + \tau_s} HV e^{-at}$$

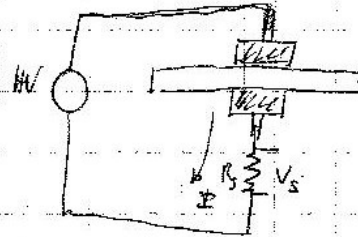
We wait until the voltage becomes steady and we use that value (after a while the voltage rises again due to the adjacent cells that start to inject current into the system or to discharge the capacitor – we do not use guard ring here)



<http://www.pv.infn.it/~vitulo/DSCN1707.MOV>

$$\frac{\tau_s}{\tau + \tau_s} HV = V_s \quad \frac{R_s \ell}{R \ell + R_s \ell} HV = V_s \quad \frac{HV}{V_s} \cdot R_s = R + R_s$$

$$\textcircled{*} \quad R = \left(\frac{HV}{V_s} - 1 \right) R_s = \rho \frac{\ell}{s}$$



$$V_s = I R_s$$

$$I = \frac{HV}{R + R_s} \quad V_s = \frac{HV}{R + R_s} \cdot R_s$$

$$R V_s + R_s V_s = HV R_s \Rightarrow R V_s = (HV - V_s) R_s \Rightarrow R = \frac{HV - V_s}{V_s} \cdot R_s$$

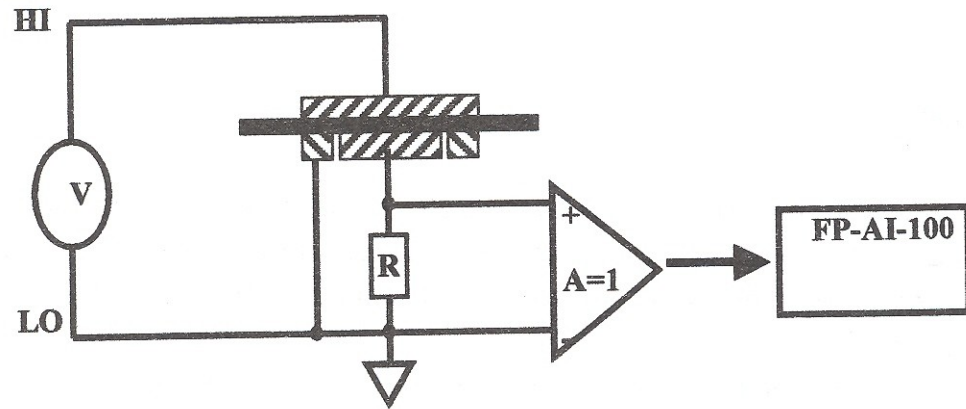
$$\Rightarrow \textcircled{*} \quad R = \left(\frac{HV}{V_s} - 1 \right) \cdot R_s$$

1) "Fixed" Instrument:

Automatic Resistivity System.

- a) 9 points of measure on the panel
- b) Electrodes made by conductive rubber (dry measurement)

9 x



Calibration:

Typically the resistivity is measured using a water soaked pad mounted on a piston. Our system uses a dry pad with safety ring and therefore a calibration is required to scale the values obtained to those of a water pad.

The calibration is performed on a small sample of HPL, whose resistivity is measured both with wet and with dry pad.

The ratio

$$A = \frac{\langle V_{H_2O} \rangle}{\langle V_i \rangle} \times 1.17$$

is then calculated and used in the automated software to correct the results.

The factor 1.17 accounts for the different geometry of the two pads.

1) Measure of $\langle V_{H_2O} \rangle$

Using the wet piston system, the voltage drop across the HPL is measured several times and the average is calculated.

2) Measure of $\langle V_i \rangle$

A LABView software allows to measure the voltage drop on each of the nine dry pistons V_i .

The measure has to be performed using the same HPL sample used for the wet system under piston i , and using other eight spare HPL plates for the other pistons.

After one measurement the sample is moved to another piston until all of them are measured.

The average $\langle V_i \rangle$ is used to calculate **A**. Furthermore the ratio $\sigma[V_i]/\langle V_i \rangle$ provides an idea of the error in the measurement of a full plate: typically such ratio is comprised between 10% and 15%.

Temperature

For our purposes the range of values is $1-6 \times 10^{10} \Omega \text{cm}$.

Resistivity is usually done at $T=20^\circ \text{C}$, so if a measure has to be performed at T_{amb} , a formula can be used to correct it:

$$\frac{\rho_{20}}{\rho_{T_{\text{amb}}}} = e^{\alpha(T_{\text{amb}}-20)}$$

Where α is a function of the percentual humidity H%.

The software automatically measures and saves T_{amb} , however it is recommended to measure the temperature on the plate, since typically the HPL has a higher termical capacitance.

The difference between ambience and plate can be inserted in the formula through the **DTc** value. $\text{DTc} = T_{\text{amb}} - T_{\text{plate}}$

The value of α can be obtained from a table